

EV026157252

Sheet 1 of 2

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. MI22-1965		SERIAL NO. Unknown		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.				
				FILING DATE Filed herewith		GROUP Unknown		
U.S. PATENT DOCUMENTS								
*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate		
DLO	AA	5,254,489	10/19/93	Nakata	437	40		
	AB	5,464,792	11/7/95	Tseng et al.	437	160		
	AC	5,620,908	4/15/97	Inoh et al.	438	207		
	AD	5,716,864	2/10/98	Abe	437	43		
	AE	5,972,783	10/26/99	Arai et al.	438	513		
	AF	5,674,788	10/1997	Wristers et al.	437	239		
	AG	5,960,302	09/1999	Ma et al.	438	585		
	AH	5,994,749	11/1999	Oda	257	411		
	AI	6,225,151 B1	05/2001	Gardner et al.	438	162		
	AJ	4,651,406	03/1987	Shimizu et al.	29	571		
DLO	AK	5,502,009	03/1996	Lin	437	239		
FOREIGN PATENT DOCUMENTS								
	Document Number	Date	Country	Class	Subclass	Translation		
						Yes	No	
DLO	AL	6302813 A	04/1993	Japan				
	AM	WO 96/39713	6/1996	Wristers et al.				
	AN							
	AO							
	AP							
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
DLO	AR		C.T. Liu et al.; "Multiple Gate Oxide Thickness for 2GHz System-on-A-Chip Technologies"; IEEE 1998; pp. 21.2.1-21.2.4					
DLO	AS		Kuroi et al., "The Effects of Nitrogen Implantation Into P + Poly-Silicon Gate on Gate Oxide Properties", 1994 Symposium on VLSI Technology Digest of Technical Papers, pp. 107-108.					
DLO	AT		Doyle et al., "Simultaneous Growth of Different Thickness Gate Oxides in Silicon CMOS Processing", IEEE Electron Device Letters, Vol. 16, No. 7.					
EXAMINER <i>Douglas W. Owens</i>				DATE CONSIDERED <i>7/4/02</i>				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

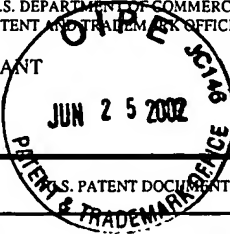
 J1046 U.S. PTO
 10/00/416

02/27/02

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1965	SERIAL NO. Unknown		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.			
				FILING DATE Filed herewith	GROUP Unknown		
U.S. PATENT DOCUMENTS							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
DKJ	AA	6,136,654	10/2000	Kraft et al.	438	287	
DKJ	AB	6,165,846	12/2000	Carns et al.	438	264	
DKJ	AC	6,200,834 B1	03/2001	Bronner et al.	438	142	
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation
							Yes No
	AL						
	AM						
	AN						
	AO						
	AP						
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)							
DKJ	AR		Ko et al., "The Effect of Nitrogen Incorporation Into the Gate Oxide by Using Shallow Implantation of Nitrogen and Drive-in Process", 1998 IEEE, 0-7803-4932-6/98.				
	AS						
	AT						
EXAMINER Douglas W. Orens				DATE CONSIDERED 7/11/02			
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1965		SERIAL NO. 10/087,416		
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.				
				FILING DATE Filed herewith		GROUP 2811		
PATENT DOCUMENTS								
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA							
	AB							
	AC							
	AD							
	AE							
	AF							
	AG							
	AH							
	AI							
	AJ							
	AK							
FOREIGN PATENT DOCUMENTS								
		Document Number	Date	Country	Class	Subclass	Translation	
							Yes	No
	AL	326352-A	2001	Japan (Abstract provided w/untranslated patent)				
	AM							
	AN							
	AO							
	AP							
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)								
	AR							
	AS							
	AT							
EXAMINER				DATE CONSIDERED				
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.								

Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO. M122-1965	SERIAL NO. 10/087,416
LIST OF ART CITED BY APPLICANT (Use several sheets if necessary)				APPLICANT Jigish D. Trivedi et al.	
				FILING DATE February 27, 2002	GROUP 2811



U.S. PATENT DOCUMENTS							
*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
DKO	AA	5,596,218	01/1997	Soleimani et al.			
DKO	AB	6,153,538	11/2000	An			
DKO	AC	5,763,922	06/1998	Chau			
	AD						
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

FOREIGN PATENT DOCUMENTS							
Document Number	Date	Country	Class	Subclass	Translation		
					Yes	No	
AL							
AM							
AN							
AO							
AP							

OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)			
	AR		
	AS		
	AT		

EXAMINER <i>Douglas W. Owens</i>	DATE CONSIDERED <i>7/11/02</i>
-------------------------------------	-----------------------------------

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.